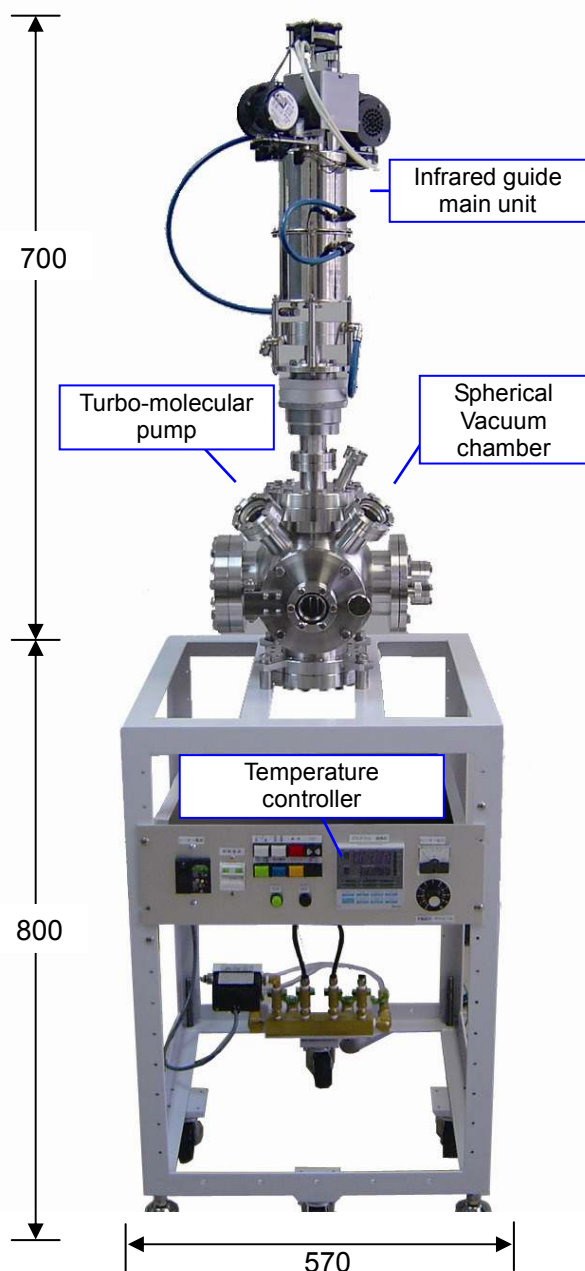




Introducing infrared radiation from a heat source on the atmosphere side into a vacuum chamber to irradiate samples. Ultra High Temperature and Clean Heating!



[Features]

1. Ultra high-speed heating of only the sample without the surrounding area.
2. Non-contact and clean heating. No contamination.
3. Heating in vacuum
4. Low power and high temperature attainment (energy-saving heating)

[Major Specifications]

Max. attainable temperature: 1500°C

Max. heating rate: 150°C/sec.

Heating method: Program control

Infrared emission part: 20 mm dia.
25 mm vertical movement

Attainable vacuum degree: 5×10^{-4} Pa

[Applications]

- Ultra high-speed heating of new materials such as Silicon, Silicon carbide, and Graphene
- Production of thin films and oxide crystals
- Laser ablation and Thermal Desorption Spectrometer
- Installation into X-ray Photoelectron Spectrometer

[Standard Configuration]

1. Infrared guide main unit (GVL298)
2. Spherical vacuum chamber (TW10)
3. Temperature controller (TP300FF)
4. High-vacuum exhaust device and Vacuum gauge
5. Safety circuit and Installation frame

[Options]

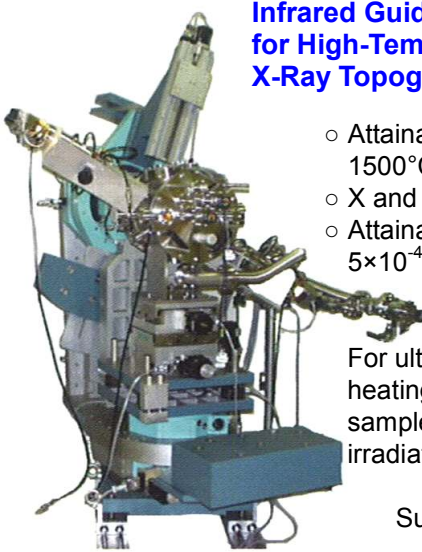
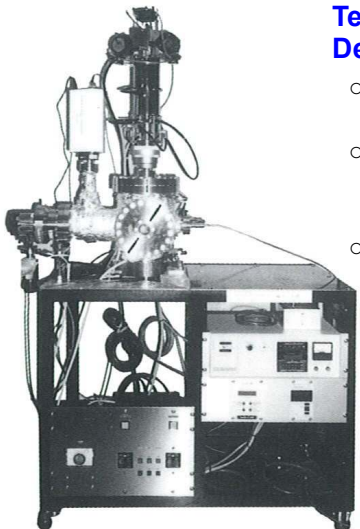



1. Movable thermal sensor (RS250-V)
2. Infrared thermal sensor (IR2S)
3. Gas atmosphere mechanism
4. Sample observation mechanism
5. Optical analysis mechanism
6. Cooling water circulation system



Specifications of Infrared Guide Section

Infrared guide section, Main unit	High-speed heating model		Ultra high-vacuum model	
	GV198	GVL298	GVH198	GVH298
Max. attainable temperature	1300°C	1500°C	1200°C	1400°C
Heating area diameter	Approx. 20 mm dia.			
Leakage	1.33×10 ⁻⁸ Pa·m ³ /sec. max.		1.33×10 ⁻¹⁰ Pa·m ³ /sec. max.	
Max. attainable vacuum degree	5×10 ⁻⁷ Pa *Note 1		5×10 ⁻⁹ Pa *Note 1	
Max. heating rate	100–150°C/sec.		1°C/sec.	

*Note 1: Varies depending on the attainable vacuum degree of the installed vacuum system.

<p>GVL298-2 Infrared Guide Heating System for High-Temperature X-Ray Topography</p>  <ul style="list-style-type: none"> ○ Attainable temperature: 1500°C ○ X and Y rotation of sample ○ Attainable vacuum degree: 5×10⁻⁴ Pa <p>For ultra high-temperature heating of X-ray irradiated samples through two-sided irradiation of infrared rays.</p> <p>Supplied to: Spring-8</p>	<p>GV2H Temperature Desorption Spectrometer</p>  <ul style="list-style-type: none"> ○ Attainable temperature: 1500°C ○ Heating rate: 1500°C achievable in approx. 1 minute ○ Attainable vacuum degree: 5 × 10⁻⁶ Pa min. <p>High-speed heating of samples enclosed in an ultrahigh vacuum and for the detection of infinitesimal gas emissions.</p> <p>Supplied to: Kyoto University</p>
<p>Example of GVH model installed on an X-ray photoelectron spectrometer</p> <p>GVH298 Ultra High-vacuum Model</p>  <ul style="list-style-type: none"> ○ Attainable temperature: 1400°C ○ Attainable vacuum degree: 5×10⁻⁹ Pa <p>Supplied to: Tokyo City University</p>	<p>High-vacuum Exhaust Device (HC80V)</p>  <p>Rapidly exhausts air from the vacuum chamber.</p> <p>Vacuum Gauge (PK251)</p> 

We reserve the right to modify the specifications, appearance, and other features of the products described herein at any time and without prior notice. (3.2011)

Contact below for specifications and details of the system.



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